Nanostructured Semiconductor Films

Nanostructured TiO₂ Films

We employ colloidal route to prepare nanostructured TiO2 films. The method is useful for casting mesoscopic TiO2 films on conducting glass electrodes and can be employed in constructing photochemical solar cells.

(Acknowledgment: Thanks to NREL scientists for providing us this recipe)

Nanostructured SnO₂ Films

See our original reference

Bedja, I., Hotchandani, S. and Kamat, P. V., Preparation and characterization of thin SnO2 nanocrystalline semiconductor films and their sensitization with bis(2,2'-bipyridine)(2,2'-bipyridine-4-4'-dicarboxylic acid)ruthenium complex. J. Phys. Chem., 1994, 98, 4133-4140.

Nanostructured ZnO Films

See our original reference

Hotchandani, S. and Kamat, P. V., Photoelectrochemistry of semiconductor ZnO particulate films. J. Electrochem. Soc., 1992, 139, 1630-4.

Modification of oxide films with CdS

See our original reference

Hotchandani, S. and Kamat, P. V., Modification of electrode surface with semiconductor colloids and its sensitization with chlorophyll a. Chem. Phys. Lett., 1992, 191, 320-6.

Hotchandani, S. and Kamat, P. V., Charge-transfer processes in coupled semiconductor systems. Photochemistry and photoelectrochemistry of the colloidal CdS-ZnO system. J. Phys. Chem., 1992, 96, 6834-9.